WE CLAIM:

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- 1. A process for producing a carboxylic acid/diol mixture, said process comprising:
- (a) removing in a liquor exchange zone impurities from a carboxylic acid slurry to form a water-wet carboxylic acid cake, a mother liquor stream, a solvent mother liquor stream, and a solvent/water byproduct liquor stream;
 - (b) routing said water-wet carboxylic acid cake to a vapor seal zone; and
- (c) adding at least one diol to said water-wet carboxylic acid cake in a carboxylic acid/diol mixing zone to form said carboxylic acid/diol mixture.
 - 2. A process according to claim 1 wherein said carboxylic acid is selected from a group consisting of terephthalic acid, isophthalic acid, naphthalene dicarboxylic acid, trimellitic acid, and mixtures thereof.
 - 3. A process according to claim 1 or 2 wherein said diol is selected from the group consisting of ethylene glycol, diethylene glycol, n-butylene glycol, i-butylene glycol, n-propylene glycol, 1,4 butanediol, cyclohexanedimethanol, and mixtures thereof.
- 4. A process according to claim 1 wherein said carboxylic acid/diol mixing zone comprises at least one device selected from the group consisting of an agitated vessel, a static mixer, a screw conveyor, and a PET esterification reactor.

- 5. A process according to claim 1 wherein said carboxylic acid is terephthalic acid and said diol is ethylene glycol.
- 6. A process for producing a carboxylic acid/diol mixture, said process comprising:
- 5 (a) removing in a solvent liquor exchange zone impurities from a carboxylic acid slurry to form a carboxylic acid cake with solvent, a mother liquor stream, and a solvent mother liquor stream;
 - (b) adding water in a water wash zone to said carboxylic cakewith solvent to produce a water-wet carboxylic acid cake and asolvent/water by product liquor stream;

- (c) routing said water-wet carboxylic acid cake to a vapor seal zone; and
- (d) adding at least one diol to said water-wet carboxylic acid cake
 in a carboxylic acid/diol mixing zone to form said carboxylic acid/diol
 mixture.
 - 7. A process according to claim 6 wherein said carboxylic acid is selected from a group consisting of terephthalic acid, isophthalic acid, naphthalene dicarboxylic acid, trimellitic acid and mixtures thereof.
- A process according to claim 6 or 7 wherein said diol is selected
 from the group consisting of ethylene glycol, diethylene glycol, n-butylene glycol, i-butylene glycol, n-propylene glycol, 1,4 butanediol,
 cyclohexanedimethanol, and mixtures thereof.

- 9. A process according to claim 6 wherein said carboxylic acid/diol mixing zone comprises at least one device selected from the group consisting of an agitated vessel, a static mixer, a screw conveyor, and a PET esterification reactor.
- 5 10. A process according to claim 6 wherein said carboxylic acid is terephthalic acid and said diol is ethylene glycol.
 - 11. A process for producing a carboxylic acid/diol mixture, said process comprising:
 - (a) removing in a solid-liquid separation zone impurities from a carboxylic acid slurry to form a slurry or cake carboxylic acid product and a mother liquor stream;

- (b) removing in a solvent-water liquor exchange zone residual impurities from said slurry or cake carboxylic acid product to form a waterwet carboxylic acid cake, a solvent mother liquor stream, and a solvent/water byproduct liquor stream;
 - (c) routing said water-wet carboxylic acid cake to a vapor seal zone; and
- (d) adding at least one diol to said water-wet carboxylic acid cake in a carboxylic acid/diol mixing zone to form said carboxylic acid/diol
 20 mixture.
 - 12. A process according to claim 11 wherein said carboxylic acid is selected from a group consisting of terephthalic acid, isophthalic acid, naphthalene dicarboxylic acid, trimellitic acid and mixtures thereof.

- 13. A process according to claim 11 or 12 wherein said diol is selected from the group consisting of ethylene glycol, diethylene glycol, n-butylene glycol, i-butylene glycol, n-propylene glycol, 1,4 butanediol, cyclohexanedimethanol, and mixtures thereof.
- 5 14. A process according to claim 11 wherein said carboxylic acid/diol mixing zone comprises at least one device selected from the group consisting of an agitated vessel, a static mixer, a screw conveyor, and a PET esterification reactor.
- 15. A process according to claim 11 wherein said carboxylic acid isterephthalic acid and said diol is ethylene glycol.
 - 16. A process for producing a carboxylic acid/diol mixture, said process comprising the following steps:
 - (a) removing a solvent from a slurry or cake carboxylic acid product in a solvent-water liquor exchange zone; wherein a substantial portion of the solvent in said slurry or cake carboxylic acid product is replaced with water to form a water-wet carboxylic acid cake;

- (b) routing said water-wet carboxylic acid cake to a vapor seal zone; and
- (c) adding at least one diol to said water-wet carboxylic acid cake
 in a carboxylic acid/diol mixing zone to form said carboxylic acid/diol mixture.

- 17. A process according to claim 16 wherein said carboxylic acid is selected from a group consisting of terephthalic acid, isophthalic acid, naphthalene dicarboxylic acid, trimellitic and mixtures thereof.
- 18. A process according to claim 16 or 17 wherein said diol is selected from the group consisting of ethylene glycol, diethylene glycol, n-butylene glycol, i-butylene glycol, n-propylene glycol, 1,4 butanediol, cyclohexanedimethanol, and mixtures thereof.
 - 19. A process according to claim 16 wherein said carboxylic acid/diol mixing zone comprises at least one device selected from the group consisting of an agitated vessel, a static mixer, a screw conveyor, and a PET esterification reactor.

- 20. A process for producing a terephthalic acid/diol mixture, said process comprising:
- (a) removing in a solvent wash zone residual impurities from aslurry or cake terephthalic acid product to form a terephthalic acid cake with acetic acid:
 - (b) removing a substantial portion of a solvent in a water wash zone from said terephthalic acid cake with acetic acid to form a water-wet terephthalic acid cake; and
- 20 (c) routing said water-wet terephthalic acid cake to a vapor seal zone; and

- (d) adding at least one diol to said water-wet terephthalic acid cake in a carboxylic acid/diol mixing zone to form said terephthalic acid/diol mixture.
- 21. A process according to claim 20 wherein said solvent wash zone
 5 comprises a solid-liquid separation device that is operated at a temperature
 between about 40 °C to about 155 °C.
 - 22. A process according to claim 21 wherein said water wash zone comprises a solid-liquid separation device that is operated at a temperature between about 40 °C to about 155 °C.
- 23. A process according to claim 20 or 21 wherein said adding occurs at a temperature between about 40 °C to about 290 °C.
 - 24. A process according to claim 20 wherein said diol is selected from the group consisting of ethylene glycol, diethylene glycol, n-butylene glycol, i-butylene glycol, n-propylene glycol, 1,4 butanediol,
- 15 cyclohexanedimethanol, and mixtures thereof.

- 25. A process according to claim 20 wherein said diol is ethylene glycol.
- 26. A process according to claim 20 wherein said carboxylic acid/diol mixing zone comprises a device selected from the group consisting of an agitated vessel, a static mixer, a screw conveyor, and a PET esterification reactor.
- 27. A process for producing a terephthalic acid/diol mixture, said process comprising:

- (a) removing a solvent from a slurry or cake terephthalic acid product in a solvent-water liquor exchange zone; wherein a substantial portion of the solvent in said slurry or cake terephthalic acid product is replaced with water to form a water-wet terephthalic acid cake;
- (b) routing said water-wet terephthalic acid cake to a vapor seal zone; and

- (c) adding at least one diol to said water-wet terephthalic acid cake in a carboxylic acid/diol mixing zone to form said terephthalic acid/diol mixture.
- 28. A process according to claim 27 wherein said solvent liquor exchange zone comprises a solid-liquid separation device that is operated at a temperature between about 40 °C to about 155 °C.
 - 29. A process according to claim 27 wherein said adding occurs at a temperature between about 40 °C and 290 °C.
- 30. A process according to claim 27 wherein said diol is selected from the group consisting of ethylene glycol, diethylene glycol, n-butylene glycol, i-butylene glycol, n-propylene glycol, 1,4 butanediol, cyclohexanedimethanol, and mixtures thereof.
 - 31. A process according to claim 27 wherein said diol is ethylene glycol.
- 32. A process according to claim 27 wherein said carboxylic acid/diol mixing zone comprises a device selected from the group consisting of an agitated vessel, a static mixer, a screw conveyor, and a PET esterification reactor.

- 33. A process for producing a terephthalic acid/diol mixture, said process comprising:
- (a) removing in a solvent wash zone residual impurities from a slurry or cake terephthalic acid product from a terephthalic acid cake with acetic acid; wherein said solvent wash zone comprises at least one solid-liquid separation device that is operated at a temperature between about 40 °C to about 155 °C;

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- (b) removing a substantial portion of a solvent in a water wash zone from said terephthalic acid cake with acetic acid to form a water-wet terephthalic acid cake; wherein said water wash zone comprises at least one solid-liquid separation device that is operated at a temperature between about 40 °C to about 155 °C;
- (c) routing said water-wet terephthalic acid cake to a vapor seal zone; and
- (d) adding at least one diol to said water-wet terephthalic acid cake in a carboxylic acid/diol mixing zone to form said terephthalic acid/diol mixture; wherein said adding occurs at a temperature between about 40 °C to about 290 °C; wherein said diol is ethylene glycol.
- 34. A process for producing a carboxylic acid/diol mixture, said process20 comprising:
 - (a) removing in a solid-liquid separation zone impurities from a carboxylic acid slurry to form a slurry or cake carboxylic acid product and a mother liquor stream;

- (b) adding solvent to a slurry or cake carboxylic acid product in a solvent wash zone to said slurry or cake carboxylic acid product to produce a carboxylic acid cake with solvent and a solvent mother liquor stream;
- (c) optionally, adding water in a water wash zone to said
 carboxylic cake with solvent to produce a water-wet carboxylic acid cake
 and a solvent/water by product liquor stream;

- (d) routing said water-wet carboxylic acid cake or said carboxylic acid cake with solvent to a vapor seal zone; and
- (e) adding at least one diol to said water-wet carboxylic acid cakein a carboxylic acid/diol mixing zone to form said carboxylic acid/diol mixture.
 - 35. A process according to claim 34 wherein said carboxylic acid is selected from a group consisting of terephthalic acid, isophthalic acid, naphthalene dicarboxylic acid, trimellitic acid and mixtures thereof.
- 15 36. A process according to claim 34 or 35 wherein said diol is selected from the group consisting of ethylene glycol, diethylene glycol, n-butylene glycol, i-butylene glycol, n-propylene glycol, 1,4 butanediol, cyclohexanedimethanol, and mixtures thereof.
- 37. A process according to claim 34 wherein said carboxylic acid/diol
 20 mixing zone comprises at least one device selected from the group consisting of an agitated vessel, a static mixer, a screw conveyor, and a PET esterification reactor.

- 38. A process according to claim 34 wherein said carboxylic acid is terephthalic acid and said diol is ethylene glycol.
- 39. A process for producing a terephthalic acid/diol mixture, said process comprising:
- 5 (a) removing in a solid-liquid separation zone impurities from a terephthalic acid slurry to form a slurry or cake terephthalic acid product and a mother liquor stream;
 - (b) adding solvent in a solvent wash zone to said slurry or cake terephthalic acid product to produce a terephthalic acid cake with solvent and a solvent mother liquor stream;
 - (c) optionally, adding water in a water wash zone to said
 terephthalic acid cake with solvent to produce a water-wet terephthalic acid
 cake and a solvent/water by product liquor stream;
 - (d) routing said water-wet terephthalic acid cake or said carboxylic acid cake with solvent to a vapor seal zone; and

- (e) adding at least one diol to said water-wet terephthalic acid cake in a carboxylic acid/diol mixing zone to form said terephthalic acid/diol mixture.
- 40. A process according to claim 39 wherein said solvent wash zone
 20 comprises a solid-liquid separation device that is operated at a temperature
 between about 40 °C to about 155 °C.

- 41. A process according to claim 40 wherein said water wash zone comprises a solid-liquid separation device that is operated at a temperature between about 40 °C to about 155 °C.
- 42. A process according to claim 39 or 40 wherein said adding occurs at a temperature between about 40 °C and about 290 °C.
 - 43. A process according to claim 39 wherein said diol is selected from the group consisting of ethylene glycol, diethylene glycol, n-butylene glycol, i-butylene glycol, n-propylene glycol, 1,4 butanediol, cyclohexanedimethanol, and mixtures thereof.
- 10 44. A process according to claim 39 wherein said diol is ethylene glycol.
 - 45. A process according to claim 39 wherein said carboxylic acid/diol mixing zone comprises a device selected from the group consisting of an agitated vessel, a static mixer, a screw conveyor, and a PET esterification reactor.
- 15 46. A process according to claim 34 or 39 wherein said solvent is added counter current to the flow of said slurry or cake carboxylic acid product.
 - 47. A process according to claim 34 or 39 wherein said water is added counter current to the flow of said carboxylic acid cake with solvent.
- 48. A process according to claim 46 wherein said water is added counter current to the flow of said carboxylic acid cake with solvent.
 - 49. A process according to claim 48 wherein said water wash zone comprises from about 2 to about 4 stages of water counter current washes.

- 50. A process according to claim 46 wherein said solvent wash zone comprises from about 2 to about 4 stages of solvent counter current washes.
- 51. A process according to claim 47 wherein said water wash zone
- 5 comprises from about 2 to about 4 stages of water counter current washes.